Temperature Difference Leads to Magnetism

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**Heat field.** Heating the right edge of an n-type semiconductor on top of a p-type semiconductor leads to loops of current in each material that generate a magnetic field pointing out of the screen, according to computer simulations.

Computer simulations suggest that creating hot and cold regions within a specific arrangement of semiconductors generates internal electric currents and magnetic fields. If borne out by experiments, the new effect, reported 8 July in *Physical Review B*, could lead to improvements in electronic devices that heat up in use. Experts are intrigued by the effect but remain cautious about its practical importance until they see experimental data.

Temperature differences, or "gradients," can have important effects on the flow of current in a semiconductor because the electrons or holes tend to drift from hotter regions toward colder ones. Such thermal effects can also interact with electric and magnetic fields, as in the so-called thermoelectromagnetic effects. For instance, in the Nernst effect, when a semiconductor is exposed to a temperature gradient and a magnetic field at right angles to each other, a small electric field is produced in the third direction. Semiconductors in electronic devices often develop temperature gradients, so
researchers need to understand their effects.

Junqiao Wu of the University of California, Berkeley, and his colleagues noticed that in the known thermoelectromagnetic effects, the magnetic field is never induced but always one of the "inputs," or applied fields. They wondered whether a magnetic field would result if a semiconductor were subjected to an electric field and a temperature gradient.

The team ran computer simulations of a two-micron-wide sample consisting of an n-type semiconductor (electrons carry current) on top of a p-type semiconductor (positively-charged holes carry current). Near the interface, such a structure—which is common in electronics—generates a so-called depletion region, where electrons diffuse down into the p-type material and holes diffuse up into the n-type material. The fixed charges left behind create an electric field pointing down. Next, the team's simulation assumed that the left edge was 10 millikelvin cooler than room temperature, and the right edge was 10 millikelvin hotter.

In the simulations, a current vortex developed in each material. In the n-type semiconductor, which was on top, electrons moved to the right at the top edge and to the left just above the interface, with the holes executing nearly a mirror image of this motion below the interface, in the p-type material. These vortices generated a magnetic field that pointed outward, toward the viewer.

The vortices are results of a complex simulation, and it's difficult to explain them in physical terms. But part of the story is that half of each loop of current goes through the depletion region, the area within perhaps 100 nanometers of the p/n interface, where there are fewer charge carriers than in the rest of the material. This lack of charge carriers turns out to allow the temperature gradient to have a stronger effect on the mobile charges that remain there—pushing them from right to left—than it has on charges outside the depletion region. Away from this zone, near the upper and lower edges of the structure, there is much higher conductivity, which allows the charges to more easily flow left-to-right, against their usual thermal diffusion direction.

In addition, the vertical electric field effectively acts at the center of charge of the electron or hole "cloud," whereas the temperature gradient acts at the center of mass, says Wu. He says that perpendicular forces acting at different places generate a torque on the charges, which partly explains the rotation, an effect described theoretically by others in 2005 [1].

The magnitude of the effect can be large, and the eddy currents could soak up energy if the structure were part of a circuit, the researchers say. In fact, Wu says, similar arrangements of semiconductors in commercial devices that heat up may be running with slightly reduced efficiency because of this effect. The solution would be to minimize the vortices by aligning the direction of the temperature gradient with that of the electric field in future designs. The team believes that a better understanding of the relationships among temperature, currents, and electromagnetic fields may help engineers improve electronic designs in other ways as well.

Gang Chen of the Massachusetts Institute of Technology in Cambridge says Wu's paper "certainly points
to an interesting phenomenon that should be further explored" with experiments. Charles Marcus of Harvard University agrees, saying whether "it has technological relevance [would] depend on the magnitude." Wu says his team is currently designing experimental tests.

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References:


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Phys. Rev. B 84, 045205
(issue of July 2011)
Electrothermally driven current vortices in inhomogeneous bipolar semiconductors

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(Received 9 February 2011; revised manuscript received 23 March 2011; published 8 July 2011)

We report an effect that occurs in semiconductors where internal electrical fields interact with a temperature gradient. Steady current vortices and a magnetic field develop in the system, even without external carrier injection. The effect is electrodynamic, energy dissipative, and fundamentally distinct from any previously described electrophysical effects. In bipolar structures the effective thermopower can be significantly modified by the vortices. Joule heating arising from the vortices reduces the thermal conductivity by an amount comparable to the electronic thermal conductivity.

DOI: 10.1103/PhysRevB.84.045205 PACS number(s): 72.20.Pa, 73.50.Lw

I. INTRODUCTION

Free carriers motion in a semiconductor can be driven by electric fields (E), magnetic fields (B), and/or temperature gradients (∇T). Two of these fields applied in orthogonal directions generate a third field in the direction perpendicular to both, which lead to four transverse electrothermoelectromagnetic effects, known as the Hall effect (Ex × By → Ez), the Right–Leduc effect (∂xT × By → ∂zT), the Nernst effect (∂yT × Bx → ∂zT), and the Etingshausen effect (Ex × Bx → ∂zT). A common feature of all these four known effects is that B is on the input side to exert the Lorentz force, which induces the transverse VT for E. The possibility of inducing a transverse B, rather than using it as an input, had been rarely investigated. Using a generic hydrodynamic model, Mohseni et al. recently showed that electron-flow vortices may arise in inhomogeneous semiconductors driven by a net torque, which is caused by the fact that inside a differential charge flow element, E acts on the center of charge whereas VT acts on the center of mass of the free carriers. In this work, by applying a detailed electromagnetic drift-diffusion model to a practical device structure, we show that when a VT is applied in perpendicular to an E field, steady current vortices develop in the system even in the absence of external carrier injection (i.e. open circuit condition). The vortices then give rise to a transverse B field (∂xT × Ex → Bz), defining an effect that is electrodynamic and energy dissipative. This is fundamentally distinct from the previously described four electrothermoelectromagnetic effects which are all electrostatic in the transverse direction in the steady state.

We show that such current vortices significantly modify the effective thermopower (Seebeck coefficient) in bipolar structures, and Joule heating arising from the vortices can reduce the thermal conductivity by an amount comparable to the electronic thermal conductivity. Internal E fields naturally occur in inhomogeneous materials, which are frequently encountered in the search for high thermopower and simultaneous high electrical conductivity in modern thermoelectric devices. Moreover, surface or grain-boundary Fermi-level pinning and composition fluctuation can also render the system electronically inhomogeneous. With potentially high thermoelectric performance from nanostructures and nanocomposites, it is critically important to understand the interaction between VT and E fields, and the consequent electrothermal properties in inhomogeneous semiconductor structures.

II. SIMULATION DETAILS

We consider a prototypical case where the E field is internal and produced by doping variation: a bipolar semiconductor structure with an N-type and P-type region. In isothermal equilibrium, gradient in free charge carrier density drives the diffusion current, redistributes the carriers, and develops the internal built-in E field, until it is balanced by the drift current driven by the E field. However, when a temperature gradient is present, these local currents are not necessarily balanced and cancelled by the VT driven current, because in general they can have nonzero components orthogonal to each other. In steady state, the net current in an N-type, isotropic but inhomogeneously doped semiconductor is,}

\[
\mathbf{j}_n(r) = -\sigma_n(r)\nabla \phi(r) - \frac{e}{\sigma_n(r)} S_n(r) \nabla T(r) = -\sigma_n(r) \left[ \nabla E_{FN}(r) / e + S_n(r) \nabla T(r) \right]
\]

where \( E_{FN}(r) \) is the electron quasi-Fermi level (electrochemical potential) taking into account both the internal E field \( \mathbf{E}(r) = -\nabla \phi(r) \) and the electron density gradient \( \nabla n(r) \); \( \sigma_n(r) \) and \( S_n(r) \) are the local electrical conductivity and thermopower, respectively. The electrochemical emf, defined by the difference in \( E_{FN}(r) \) between the measured points A and B, is

\[
emf_{AB} = \int_A^B \nabla E_{FN}(r) d\mathbf{l}
\]

It should be noted that this \( emf_{AB} \) is the total electrically \( [\nabla \phi(r)] \) and chemically \( [\nabla n(r)] \) driven electromotive force and is responsible for the Seebeck voltage builtup between points A and B. The net current is driven by this electrochemical emf in conjunction with the thermal emf, the latter being...
the second term in Eq. (2), \( \int_A^B S_n(r) \nabla T(r) \, d\mathbf{l} \). For simplicity, \( emf_{AB} \) in this paper refers to the electrochemical \( emf \) defined in Eq. (2). In the presence of internal current \( j_i(r) \), the effective thermopower \( S_{AB} = emf_{AB}/(T_B - T_A) \) is generally no longer equal to the simple spatial average of local thermopower \( S_n(r) \) as given merely by the second term in Eq. (2). For bipolar conduction, Eq. (2) is extended by including both electron and hole conduction, as discussed in Ref. 14

\[
emf_{AB} = \int_A^B \frac{[j_n(r) + j_p(r)] d\mathbf{l}}{\sigma_n(r) + \sigma_p(r)} + \int_A^B \frac{\sigma_n(r) S_n(r) + \sigma_p(r) S_p(r)}{\sigma_n(r) + \sigma_p(r)} \nabla T(r) \, d\mathbf{l}.
\]  

(3)

It is shown below that in inhomogeneous structures under thermal bias, the current term is generally nonzero due to the interaction between the built-in \( \mathbf{E} \) field and \( VT \). When the size of the system is comparable to the carrier depletion length, the effective thermopower is significantly different from what is expected in the static bipolar model given by the second term in Eq. (3), necessitating a dynamic electrophysical model to fully describe the system.

A Si P-N junction with a transverse thermal bias, is shown in Fig. 1(a). In contrast to previously simulated P-N junctions with a longitudinal\(^\text{15}\) or local transverse thermal bias,\(^\text{16}\) here the temperature variation is macroscopic and is not limited to the direction parallel to the built-in \( \mathbf{E} \) field, so that the thermal driving force [the \( VT \) term in Eq. (1)] for carrier motion cannot be balanced by electrochemical driving forces [the \( \nabla E_{\text{F}} \) term in Eq. (1)]. Similar structures were proposed for thermoelectric power generation,\(^\text{17}\) but the formation of internal currents and their effect on the thermopower and thermal conductivity were not explored. We calculated the distribution of electric potential and quasi-Fermi energy by solving the coupled Poisson and electric current continuity equations in 2D. The electric potential \( \phi(r) \) satisfies the Poisson’s equation,

\[
\varepsilon \nabla^2 \phi(r)/|e| = -[\pm N_{d,a} - n[\phi(r)] + p[\phi(r)]],
\]

(4)

where \( N_d \) (positive sign) or \( N_a \) (negative sign) is the constant concentration of donors in the N-type region or acceptors in the P-type region, respectively, which are assumed to be fully ionized at the simulated temperature (\( T \sim 300K \)). The carrier concentrations redistribute in space because the local electric potential modulates the carrier population of the conduction and valence bands, for example,

\[
n[\phi(r)] = \int \frac{\rho_c[E - e\phi(r)]}{1 + \exp[(E - E_{\text{F}})/k_B T]} \, dE,
\]

(5)

where \( \rho_c(E) \) is the density of states for the conduction band. Full Fermi–Dirac carrier statistics are used such that the calculation is valid across all concentrations ranging from nondegenerate to degenerate. The local electron current density is given by Eq. (1), and the local \( \sigma_n(r) \) and \( S_n(r) \) are calculated from the solution to the Boltzmann transport equation under the relaxation time approximation.\(^\text{1} \) The dependence of relaxation time \( \tau_n \) on electron energy \( E \) follows \( \tau_n(E) \sim E^\beta \), where the exponent \( \beta \) is taken to be \(-1/2\), assuming acoustic phonon dominated scattering mechanism,\(^\text{18}\) and the proportional constant is obtained by fitting the calculated conductivity to experimental data. It should be emphasized that we ignored the phonon drag contribution to the Seebeck coefficient because generally it becomes significant only at low temperatures and in lightly doped semiconductors.\(^\text{19}\) A similar treatment is adopted for free-hole conduction. The temperature gradient \( \nabla T \) is set to be constant and along the \( x \) direction only, i.e. the thermal transport is assumed to be dominated by the high lattice thermal conduction, such that the effect of free carrier redistribution on \( VT \) is neglected. The system is electrically isolated from external circuit, so that no electron or hole current is allowed to flow in and out of the boundaries. The continuity equation is separately imposed for electron and hole carrier flow, so as to ensure the continuity of total current density,

\[
-\frac{1}{|e|} \nabla j_n(r) + R = \frac{1}{|e|} \nabla j_p(r) + R = 0,
\]

(6)

where nonequilibrium electrons and holes recombine non-radiatively at the rate \( R \) via midgap traps (the Shockley–Read–Hall mechanism)\(^\text{20}\) and the Auger process.\(^\text{21}\) Surface recombination rate is neglected because, as shown below, the effect occurs mostly in bulk. A finite difference method with nonuniform meshing is used to numerically solve the problem self-consistently.\(^\text{22}\)
III. RESULTS AND DISCUSSION

A. Current vortices

Figure 1(c) shows the simulated x-component electric field in steady state $E_x(r) = \partial_r \phi(r)$ for a geometry in which both the N and P layers are relatively thick. It can be seen that at the top and bottom surfaces, a nearly constant $E$ field is established in response to $VT$, with field direction depending on the type of doping. This behavior is identical to that of a homogeneous semiconductor and can be understood because the top and bottom surfaces are far from the space charge region of the P-N junction. However, deep into the structure and near the junction area, regions with electric field pointing in the “wrong” direction are found. This complicated electric field pattern is a direct consequence of the imbalanced electro-chemical-thermal driving forces for the free charge carriers. The total steady-state current $\mathbf{j}(r)$ resulting from this force imbalance is shown in Fig. 1(d). The system exhibits two current vortices distributed in the N- and P-type regions, respectively. Both vortices are counterclockwise and are nearly isolated from each other by the highly resistive space charge region at the P-N junction. It is interesting to note that at the top and bottom surfaces, the current flow direction is opposite to what one would expect for a short-circuited homogeneous semiconductor; namely, free electrons and holes flow against instead of along $VT$. This is due to the fact that the space-charge region deep in the junction area has lower free-carrier concentration than the charge neutral region, and therefore generates stronger emf to drive the free carriers to move along $-VT$; but because the neutral region is much more electrically conductive than the junction, the current forms a loop within the P or N layer by driving the carriers against $-VT$ at the top and bottom surface. The development of current vortices in this open-circuited P-N structure is not surprising, considering its similarity to the regular $\Pi$-shape thermoelectric module as shown in Fig. 1(b). In the $\Pi$-shape thermoelectric module harvesting waste heat into electricity, a P-type semiconductor and an N-type semiconductor are connected in parallel bridging a temperature difference. The $P$ and $N$ arms are electrically shorts at one end (for example, the cold side), while the other end (hot side) output current to the external load. If, however, on the hot side the two arms are also directly electrically shorted to each other, this $\Pi$ structure would become open to external circuit and be similar to the structure we simulated in Fig. 1(a). It is immediately clear that a current loop would form within this $\Pi$ structure despite that it is open to external circuit. However, differing from Fig. 1(b), the simulated structure in Fig. 1(a) has a P-N junction interfacing the $P$ and $N$ arms along the entire device length. As discussed above, it is this charge-depleted P-N junction (and its built-in $E$ field) that further redistributes the current flow and causes two vortices as shown in Fig. 1(d), instead of a single vortex as expected from the simple analogy to the $\Pi$ structure in Fig. 1(b).

B. Effects on thermopower

Despite this unusual current flow, the emf on the surfaces is still normal. The majority carrier quasi-Fermi level $E_{F+n}$ for the top surface is equal to that of an isolated, open-circuited homogeneous semiconductor doped at $N_d$. The effective thermopower $S_{\text{AB}} = \text{emf}_{\text{AB}}/(T_B - T_A)$, calculated using both terms in Eq. (3), is nearly identical to $S_{\text{AB}}^{\text{static}} = \text{emf}_{\text{AB}}^{\text{static}}/(T_B - T_A)$ calculated in the static bipolar model given solely by the second term in Eq. (3),

$$\text{emf}_{\text{AB}}^{\text{static}} = \int_A^B \frac{\sigma_n(r)\sigma_p(r)}{\sigma_n(r) + \sigma_p(r)} \nabla T(r) dl. \quad (7)$$

This $\text{emf}_{\text{AB}}^{\text{static}}$ can be easily obtained by solving the isothermal and thus static Poisson equation of the structure for $\sigma(r)$ and $S(r)$ of electrons and holes. The agreement between $\text{emf}_{\text{AB}}^{\text{static}}$ and $\text{emf}_{\text{AB}}$ is not surprising since the measured points on the surface, $A$, and $B$, are far from the junction area. The quasi-electric field [not the real electric field $E(r)$] that causes the deviation of $\text{emf}_{\text{AB}}$ from $\text{emf}_{\text{AB}}^{\text{static}}$, which is defined as

$$E'(r) \equiv \frac{j(r) + j_p(r)}{\sigma_n(r) + \sigma_p(r)}, \quad (8)$$

is very weak along the integration path from point $A$ to $B$ because the surface is not depleted and thus $\sigma(r)$ is large. This agreement, however, vanishes when the thickness of each layer is comparable to its carrier depletion length, because $E'(r)$ on the surface now becomes considerably stronger. The carrier depletion length on the $N$ side of the P-N junction can be estimated by $d_{\text{N}} = \sqrt{2\varepsilon V_{\text{bi}} N_d/(|e| N_d(N_d + N_A))}$, where $V_{\text{bi}} = k_B T \ln(N_d N_d/\ni^2)/|e|$ is the built-in voltage across the junction and $\ni$ is the intrinsic carrier concentration. Figure 1(e) plots $j(r)$ for such a structure with $N$-type layer thickness (50 nm) comparable to its depletion width (75 nm). The effective thermopower calculated is $S_{AB} = -0.55$ compared to $S_{AB}^{\text{static}} = -0.24$ mV/K, a difference of more than a factor of 2. We thereby name the full calculation of $S_{AB}$, including both terms in Eq. (3) as the dynamic electrothermal model.

Figures 2(a) and 2(b) compare $S_{AB}$ and $S_{AB}^{\text{static}}$ as a function of $N_d$ and $d_n$. When either $N_d$ or $d_n$ is large so that the measured points $A$ and $B$ are far from the depletion region, $S_{AB} \approx S_{AB}^{\text{static}}$. If $N_d$ or $d_n$ decreases so that the surface is partially depleted, $S_{AB}$ deviates significantly from $S_{AB}^{\text{static}}$, invalidating the commonly adopted static bipolar model. However, when $N_d$ or $d_n$ further decreases such that $d_n$ is much smaller than $w_n$, the $N$-type doped surface is inverted to unipolar $P$-type conduction. In this case $E'(r)$ along the top surface becomes weak again, so that $S_{AB}$ returns to $S_{AB}^{\text{static}}$, which now approaches that of the $P$ layer in the homogeneous limit. Therefore, three regimes exist in $S_{AB}$: Regime I, $d_n \gg w_n$, $S_{AB} \approx S_{AB}^{\text{static}} = S_{\text{n,bulk}}$; Regime II, $d_n \sim w_n$, $S_{AB}$ is unequal to, and more negative than $S_{AB}^{\text{static}} = (\sigma_n S_{\text{n,bulk}} + \sigma_p S_{\text{p,bulk}}) / (\sigma_n + \sigma_p)$ expected from the static bipolar model; and Regime III, $d_n \ll w_n$, $S_{AB} \approx S_{AB}^{\text{static}} = S_{\text{p,bulk}}$. Here $S_{\text{n,bulk}}$ and $S_{\text{p,bulk}}$ are the thermopower calculated for electrons and holes with the surface carrier concentrations but in the homogeneous bulk limit. In Fig. 2 we also show the prediction from a simple bilayer model that is often used to treat multilayer metallic structures, in which the effective thermopower is taken to be the bulk thermopower of each layer weighted by its sheet conductance. It can be seen that the bilayer model gives a poor prediction, especially in Regime II, because it completely neglects charge redistribution across the interface.
between layers. It is intriguing to notice the critical role of depletion length $w_n$ in gauging the size effect of $S_{AB}$ in both scenarios of varying $N_d$ and $d_n$. In the inset of Fig. 2(b) the normalized thermopower, $S_{AB}/S_{bulk}$, is plotted as a function of normalized thickness, $d_n/w_n$. It can be seen that the two sets of curves in Figs. 2(a) and 2(b) collapse onto a universal thickness dependence, regardless of whether $d_n/w_n$ is varied by directly changing $d_n$ or by varying $w_n$ through $N_d$. It is therefore clear that it is the interaction between the orthogonal built-in $E$ field and $\nabla T$ that invalidates the static bipolar model.

C. Conservativeness of electric and temperature fields

We note that in inhomogeneous structures involving bipolar charge conduction on the surface, both $emf_{AB}$ and $emf_{AB}^{static}$ are integration-path dependent. Namely, the integrands in both Eqs. (3) and (7) are nonconservative vector fields, and the loop integration of both along the closed surface loop A-B-C-D-A results in a nonzero value. Their difference $emf_{loop} = \int E(r)dl$ along the sample surface and the consequently defined $\Delta S = emf_{loop}/\Delta T$ is a characteristic thermopower correction to the entire inhomogeneous structure. $\Delta S$ can thus be used to represent the effect of inhomogeneity on thermopower of the system.

We also note that the existence of the current vortex indicates a nonzero $\nabla \times j(r)$ and a nonconservative $j(r)$ field. However, this does not imply a nonconservative $E(r) = -\nabla \psi(r)$ field or $\nabla T(r)$ field. In fact, both $\nabla \psi(r)$ and $\nabla T(r)$ are still conservative. For example, from Eq. (1) it can be seen that the Curl of the first term of the current density is

$$\nabla \times [\sigma_n(r) \nabla \psi(r)] = \nabla \sigma_n(r) \times \nabla \psi(r) + \sigma_n(r) \nabla \times [\nabla \psi(r)].$$

(9)

Therefore, even though $\nabla \times [\nabla \psi(r)] = 0$ due to the conservativeness of $\nabla \psi(r)$, Eq. (9) would still give nonzero $\nabla \times j(r)$, as long as the vector $\nabla \sigma_n(r)$ is nonzero and has a component perpendicular to $\nabla \psi(r)$. This could occur for a spatially inhomogeneous system such as the simulated one, where the built-in $E$ field of inhomogeneity redistributes free carriers and causes nonzero $\nabla \sigma_n(r)$. Considering all the current density terms in Eq. (1), $\nabla \times j(r)$ will include terms of $\nabla \sigma_n(r) \times \nabla \psi(r)$ and $\nabla \sigma_n(r) \times \nabla T(r)$. When $\nabla T(r)$ is zero or nonzero but applied in parallel to $\nabla \psi(r)$, the system can still find an electrostatic equilibrium where $\nabla \sigma_n(r)$ is adjusted to be always parallel to both $\nabla \psi(r)$ and $\nabla T(r)$ at all position $r$, hence $\nabla \times j(r) = 0$ and no current vortex is developed. However, if $\nabla T(r)$ is applied not in parallel to $\nabla \psi(r)$, the developed $\nabla \sigma_n(r)$ cannot be simultaneously parallel to both $\nabla \psi(r)$ and $\nabla T(r)$, hence the Curl of the total current density given by Eq. (1) must be nonzero, resulting in current vortices. In systems where the conduction is bipolar such as the case shown in Fig. 1(a), this process is further complicated by the existence of two types of carriers, but the current vortices originate from the same mechanism.

D. Effects on thermal conductivity

The current vortices also generate Joule heat in the structure, which effectively reduces the rate of heat transfer along $-\nabla T$. The original electronic contribution to thermal conductivity of the structure $\kappa_{electronic}$ is calculated using the Wiedemann–Franz law,

$$\kappa_{electronic} = L_0T_0 \int_{d_n}^{d_p} [\sigma_p(y) + \sigma_n(y)] dy / d_n + d_p,$$

(10)
that structure for the simulation. However, recently it was shown the depletion width on the generated by the vortices and heat transported by charge carriers in κ only L by the current vortices normalized by electronic thermal conductivity.

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FIG. 3. (Color online) Reduction in thermal conductivity caused by the current vortices normalized by electronic thermal conductivity. The structure is length \( L = 2 \text{ cm} \), \( d_i \) and \( d_p \) equal to half of the depletion width on the \( N \) and \( P \) layers, respectively; \( dT/dx = 100 \text{ K/cm} \) and \( T_0 = 300 \text{ K} \). \( W_{\text{vortex}} \) and \( W_{\text{electronic}} \) are Joule heat generated by the vortices and heat transported by charge carriers in the structure, respectively.

where \( L_0 \) is the Lorenz number\(^2\) and \( T_0 \) is averaged temperature (300 K). The electric conductivity \( \bar{\sigma} \) is averaged only along the \( y \) direction because of the parallel nature of the inhomogeneity in Fig. 1(a). We follow the treatment in Ref. 25 which assumes that half of the internal Joule heat \( (W_{\text{vortex}}/2) \) flows toward the hot side and the other half toward the cold side; the amount of \( W_{\text{vortex}} \) out of the originally transferred heat \( \kappa_{\text{total}} \Delta dT/dx \) is redistributed such that now only \( \kappa_{\text{total}} \Delta dT/dx - W_{\text{vortex}}/2 \) is completely transferred from the hot to the cold side, i.e.,

\[
\kappa'_{\text{total}} A |dT/dx| = \kappa_{\text{total}} A |dT/dx| - W_{\text{vortex}}/2. \quad (11)
\]

This defines a Joule-heating induced reduction in thermal conductivity as \( \kappa_{\text{vortex}} = W_{\text{vortex}}/(2\Delta dT/dx) \). At fixed \( \Delta T \), this reduction scales linearly with the length of the structure. In Fig. 3 we plot this reduction \( \kappa_{\text{vortex}} \) normalized by the original electronic thermal conductivity \( \kappa_{\text{electronic}} \) as a function of doping. It can be seen that the negative contribution \( \kappa_{\text{vortex}} \) can become comparable to \( \kappa_{\text{electronic}} \) when \( N_d \) and \( N_a \) are extremely asymmetric. It is noted that for bulk Si, both \( \kappa_{\text{electronic}} \) and \( \kappa_{\text{vortex}} \) are much lower than the lattice contribution to the thermal conductivity \( \kappa_{\text{lattice}} \), so they are negligible. This justifies our assumption of constant \( V T \) along the structure for the simulation. However, recently it was shown that \( \kappa_{\text{lattice}} \) may be drastically reduced via nanostructuring such as formation of nanowires, nanoporous structures, and nanomeshes.\(^3,4,5,6,7\) In these efforts, when \( \kappa_{\text{lattice}} \) is reduced to the level comparable to or below that of \( \kappa_{\text{electronic}} \) in inhomogeneous thermoelectric systems, \( \kappa_{\text{electronic}} \) and \( \kappa_{\text{vortex}} \) become considerable. Our simulated results in Fig. (3) suggest that in these nanostructures, the current vortices arising from inhomogeneities may start to strongly influence not only the thermopower, but also the electronic thermal transport.

IV. SUMMARY AND EXTENDED DISCUSSION

When the magnetic field arising from these current vortices is considered, this effect has similarities to the Nernst effect, in which a sample subjected to orthogonal \( V T \) and \( B \) field develops a lateral \( E \) field in the direction normal to both.\(^2\) However, in contrast to the Nernst effect in open circuit which is static and second order, the new effect is electrodynamic, energy-dissipative, and first order. It should be noted that a possible Hall effect induced in turn by the generated magnetic field itself was neglected in the calculation because it’s a second-order effect proportional to \( |\mathbf{j}|^2 \). The predicted results can also be extended to more complex and unipolar structures. It can be expected that for any open-circuited inhomogeneous structure, internal current vortices always exist as long as \( VT \) deviates from the direction of inhomogeneity gradient (doping, composition, Fermi-level pinning, or extended defects). However, if the inhomogeneities are deep inside the bulk such that the sample surface is electrostatically screened from their built-in electric field, the thermopower measured from the surface is equal to that of a homogeneous material with the same carrier concentration as on the surface. If the sample size is reduced such that the surface is within the depletion region, the dynamic electrothermal model developed here is needed to understand the effective thermopower. The thermopower in inhomogeneously doped semiconductors is fundamentally determined by electrothermal process in the near surface region. As such, the apparent thermopower depends on the configurational details of inhomogeneity and cannot be predicted from a simple effective medium approximation with knowledge of only the volumetric fraction of each constituent.

ACKNOWLEDGMENTS

This work was supported in part by the National Science Foundation under Grant No. CMMI-1000176 [modeling software]. D. Fu and R. Zhang acknowledge the support by Special Funds for Major State Basic Research Project (Grant No. 2011CB301901) and National Nature Science Foundation of China (Grant No. 60990311). D. Fu also acknowledges the special support of the Graduate Student Research Innovation Project of Jiangsu Province of China (Grant No. CX09B009Z).